

PGpubs

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L56	16	(photoresist with fill\$) and (((aluminum adj oxide) (silicon adj nitride) "al.sub.2o.sub.3" "sin" "Si. sub.3N.sub.4" "al.sub.2 o.sub.3" "Si.sub.3 N.sub.4" ceramic) with (ald alcvd))	US-PGPUB	OR	ON	2005/12/30 19:03

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	268	((aluminum adj oxide) "al.sub.2 o. sub.3") with ald	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L2	3213	((438/243-249) or (257/301-305)). CCLS.	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L3	18	L1 and L2	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L4	277	(jennifer near2 kennedy).xa.	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L5	2	L4 and L1	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L6	125644	((aluminum adj oxide) "al.sub.2 o. sub.3")	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L7	26	L4 and L6	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L8	274	L6 and L2	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L9	1	10/765052	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L10	1	L9 and ceramic	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L11	1	L9 and softening	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L12	0	collar with softening with resist	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L13	1	collar with soften\$ with resist	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L14	1	("6777303").PN.	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L15	1	L14 and burning	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L16	1	L14 and burn	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L17	8	L2 and (ald with ((silicon adj nitride) "si.sub.3 N.sub.4"))	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L18	170	(ald with ((silicon adj nitride) "si. sub.3 N.sub.4"))	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L19	127	(photoresist with fill\$) and (oxide with collar)	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L20	128	(photoresist with fill\$) and (oxide with collar)	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L21	80	L20 and L2	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L22	1	("6200873").PN.	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L23	0	((aluminum adj oxide) "al.sub.2 o. sub.3") and L22	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54

L24	0	(photoresist adj instead near2 polysilicon) with (suitable)	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L25	0	(photoresist adj instead near2 polysilicon) with (suitable)	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L26	0	(photoresist near instead near2 polysilicon) with (suitable)	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L27	0	(photoresist near instead near2 polysilicon) with (suitable)	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L28	0	(photoresist with instead with polysilicon) with (suitable)	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L29	0	(photoresist with instead with polysilicon) with (suitable)	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L30	1	("6200873").PN.	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L31	0	(photoresist with instead with polysilicon) with (suitable) and L30	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L32	0	(another adj sitable adj filling adj material)	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L33	0	(another adj suitable adj filling adj material)	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L34	0	(another adj suitable adj filling adj material)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 18:54
L35	0	(another adj2 suitable adj2 filling adj2 material)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 18:54
L36	3213	((438/243-249) or (257/301-305)).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L37	480	(photoresist with filling with material)	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L38	536	(photoresist with filling with material)	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L39	20	L36 and L38	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L40	86	ald with radical with plasma	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L41	0	L40 and L36	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L42	86	ald with radical with plasma	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L43	2	ald with radical with plasma with (improv\$ advantag\$ benefit\$)	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L44	0	ald with radical with plasma with ((silicon adj oxide) "sio.sub.2")	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54

L45	0	((ald with radical with plasma) same ((silicon adj oxide) "sio.sub.2")	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L46	99	((ald with plasma) same ((silicon adj oxide) "sio.sub.2")	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L47	0	((ald with plasma) with (advantag\$ benefit\$ improv\$)) same ((silicon adj oxide) "sio.sub.2")	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L48	43	((ald with plasma) with (advantag\$ benefit\$ improv\$))	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L49	21	L48 and ((silicon adj oxide) "sio. sub.2")	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L50	1	("6200873").PN.	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L51	0	L50 and (high adj aspect)	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L52	1	("6689220").PN.	US-PGPUB; USPAT	OR	OFF	2005/12/30 18:54
L53	0	L52 and radical	US-PGPUB; USPAT	OR	ON	2005/12/30 18:54
L54	23	(photoresist with fill\$) and (((aluminum adj oxide) (silicon adj nitride) "al.sub.2o.sub.3" "sin" "Si. sub.3N.sub.4" "al.sub.2 o.sub.3" "Si.sub.3 N.sub.4" ceramic) with (ald alcvd))	US-PGPUB; USPAT	OR	ON	2005/12/30 18:59
L55	20	54 not (@ad>"20040128" or @rlad>"20040128")	US-PGPUB; USPAT	OR	ON	2005/12/30 18:59